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JAPANESE PATENT OFFICE

PATENT ABSTRACTS OF JAPAN

(11) Publication number: 2004280028 A  
(43) Date of publication of application: 07.10.2004

(51) Int. Cl G02F 1/355  
// C03C 27/12

(21) Application number: 2003112145  
(22) Date of filing: 13.03.2003

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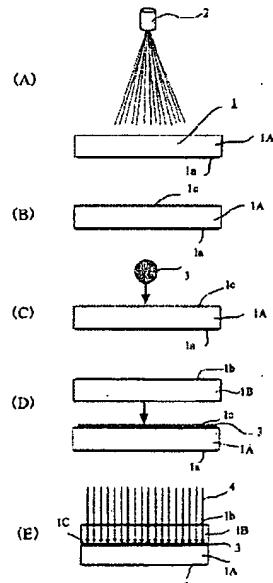
(54) SATURABLE ABSORPTION CHIP, ITS  
MANUFACTURING METHOD, AND DEVICE  
USING SATURABLE ABSORPTION CHIP

(57) Abstract:

PROBLEM TO BE SOLVED: To solve the problems with saturable absorption chips constituted by using carbon nanotubes that the chips are in a mechanically brittle state and have the structure inadequate for mass production and to improve saturable absorption.

SOLUTION: The invention comprises reinforcing the structure which is heretofore mechanically brittle by using two sheets of optical materials. In combination, the saturable absorption chips which are made suitable for mass production by using such optical materials and are provided with the chip structure having the stable saturable absorption characteristics to suppress reflection loss, the method for manufacturing the same and the saturable absorption device using the saturable absorption chips are included.

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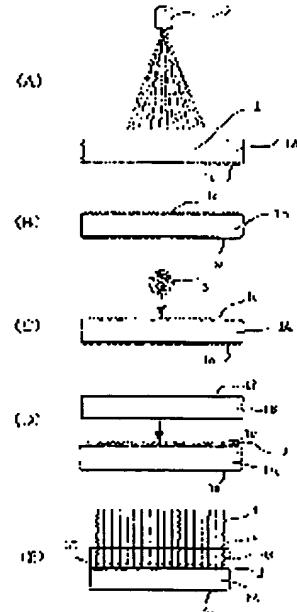
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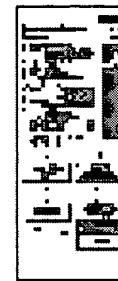
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>Title: **JP2004280028A2: SATURABLE ABSORPTION CHIP, ITS MANUFACTURING METHOD, AND DEVICE USING SATURABLE ABSORPTION CHIP**

Derwent Title: Saturable absorption chip for optical communication device, has pair of substrates made of transparent optical material, between which carbon nanotube is fixed using ultraviolet cured resin [Derwent Record](#)

Country: **JP Japan**Kind: **A2 Document Laid open to Public inspection**

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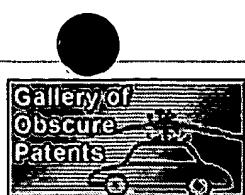
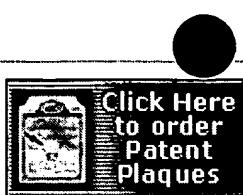
[News](#), [Profiles](#), [Stocks](#) and More about this companyPublished / Filed: **2004-10-07 / 2003-03-13**Application Number: **JP2003000112145**IPC Code: **G02F 1/355; C03C 27/12;**Priority Number: **2003-03-13 JP2003000112145**

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Family: **None**Other Abstract Info: **None**



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